

L Number	Hits	Search Text	DB	Time stamp
1	11	204/263.ccls. AND diffus\$5 NEAR membrane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/02/11 10:53
2	0	204/263.ccls. AND diffus\$5 NEAR membrane AND workpiece	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/02/11 10:53
-	14	wafer and 204/263.ccls. AND diffus\$5	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/02/11 10:47
-	9	wafer and 204/263.ccls. AND diffus\$5 AND membrane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 15:39
-	1628	wafer AND diffuser	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 15:40
-	205	wafer AND diffuser AND membrane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 15:43
-	30	wafer AND diffuser AND membrane AND 204/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 15:52
-	33	204/271.ccls. and membrane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 18:03
-	196	204/271.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 18:26
-	511	diffuser near5 membrane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 18:27
-	50620	diffuser near5 membrane same plating or electroplating	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 18:27
-	16	diffuser near5 membrane and 204/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 18:41
-	85	diffuser ADJ membrane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 18:47
-	2	diffuser ADJ membrane AND 118/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 18:46
-	85	diffuser ADJ membrane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 18:46

-	34578	diffuser ADJ membrane and workpiece or work adj piece	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 18:47
-	1	diffuser ADJ membrane and workpiece	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 18:48
-	2	diffuser ADJ membrane and work adj piece	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/16 18:48
-	25	wafer and 204/263.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/01/07 18:27
-	0	wafer and 204/263.ccls. AND diffus	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/01/07 18:27
-	14	wafer and 204/263.ccls. AND diffus\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/01/07 18:29
-	8	wafer and 204/263.ccls. AND diffus\$3 and velocity	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/01/07 18:30
-	5	wafer and 204/263.ccls. AND diffus\$3 and velocity AND membrane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/01/07 18:30